

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Offlice Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20201

STATES OF THE PARTY OF THE PART			Washington, D.C. 20201 www.uspto.gov	
APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/817,963	03/27/2001	Klaus Lowack	GR 00 P 1583	9891
75	90 10/22/2002			
LERNER AND GREENBERG, P.A.			EXAMINER	
PATENT ATTORNEYS AND ATTORNEYS AT LAW Post office Box 2480 TALBOT, BRIAN K				BRIAN K
Hollywood, FL	33022-2480		ART UNIT	PAPER NUMBER
			1762	16
			DATE MAILED: 10/22/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

<i> </i>		Application No.	Applicant(s)	/2			
Office Action Summary		09/817,963	LOWACK ET AL.	/			
		Examin r	Art Unit				
/	·	Brian K Talbot	1762				
	Th MAILING DATE of this communication app						
/	/iod for Reply						
THE N - Exter after - If the - If NO - Failui - Any ri earne	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. usions of time may be available under the provisions of 37 CFR 1.1: SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period v re to reply within the set or extended period for reply will, by statute eply received by the Office later than three months after the mailing d patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be t y within the statutory minimum of thirty (30) da vill apply and will expire SIX (6) MONTHS fron , cause the application to become ABANDON	imely filed ays will be considered timely. m the mailing date of this communic ED (35 U.S.C. § 133).	ation.			
Status	Pennancive to communication(s) filed on 14	August 2002					
1)[\]	Responsive to communication(s) filed on 14.7						
2a)⊠	•	is action is non-final.	orogogution og to the mor	rita ia			
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims						
4) Claim(s) 4-7 is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
5)□	Claim(s) is/are allowed.		,				
6)⊠	Claim(s) <u>4-7</u> is/are rejected.						
7)	Claim(s) is/are objected to.						
•	Claim(s) are subject to restriction and/o	r election requirement.					
	on Papers						
,—	The specification is objected to by the Examine						
10)	The drawing(s) filed on is/are: a) acception at the control of the control						
44)[] -	Applicant may not request that any objection to the		, ,				
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action. 12) The oath or declaration is objected to by the Examiner.							
•	•	difficition.					
Priority under 35 U.S.C. §§ 119 and 120							
	13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
<u> </u>							
	1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No.						
	 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage 						
* S	application from the International Bu See the attached detailed Office action for a list	reau (PCT Rule 17.2(a)).		,			
14) 🗌 A	cknowledgment is made of a claim for domesti	c priority under 35 U.S.C. § 119	(e) (to a provisional appli	cation).			
) \square The translation of the foreign language pro Acknowledgment is made of a claim for domest						
Attachmen	t(s)						
2) Notic	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s) <u>1</u>	5) Notice of Informa	ary (PTO-413) Paper No(s) I Patent Application (PTO-152)				
J.S. Patent and To	rademark Office						

Application/Control Number: 09/817,963

Art Unit: 1762

1. The amendment filed 8/14/02 has been considered and entered. Claims 4-7 remain in the application.

- 2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 3. In light of the amendment filed 8/14/02, the objection to the specification has been withdrawn.

Claim Rejections - 35 USC § 103

Claims 4-7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Arbach et al. (5,021,129) in combination with Angelopoulos et al. (6,136,513) further in combination with Bickford et al. (5,800,858).

Arbach et al. (5,021,129) teaches applying an electroactive layer (32) and then another electroactive layer (34). Patterning of the second layer (34) is performed to form areas (36). These areas (36) are then activated by seeding and then metallized to form conductive traces.

Angelopoulos et al. (6,136,513) teaches applying a photoresist layer to a substrate, treating the photoresist layer prior to applying a seed layer and another photoresist layer. The second photoresist layer is imaged and conductive traces are formed by metallization.

Therefore, it would have been within the skill of one practicing in the art to have modified Arbach et al. (5,021,129) process by implementing a "pretreatment step" as evidenced

Application/Control Number: 09/817,963

Art Unit: 1762

by Angelopoulos et al. (6,136,513) because of the advantages associated with such a step, i.e. reducing the amount of seeding utilized.

In addition, it would have also been within the skill of one practicing in the art to have modified Angelopoulos et al. (6,136,513) process by forming and developing the second photoresist prior to applying the seed layer as evidenced by Arbach et al. (5,021,129) because of the expectation of achieving similar results as well as the fact that the amount of seed material utilized could be reduced due to the smaller area for which the seed is applied, i.e. no waste of seed material.

Arbach et al. (5,021,129) in combination with Angelopoulos et al. (6,136,513) fail to teach the thickness of the dielectric films being not greater than 50 microns (about 2.1 mils).

Bickford et al. (5,800,858) teaches a similar process whereby the thickness of the polymer films are from 0.3 to 5 mils in thickness which are imaged, developed and seeded prior to metallization. More than one layer of the polymer can be utilized with the layers being of the same polymeric material.

Therefore, one skilled in the art would have had a reasonable expectation of achieving similar success by modifying Arbach et al. (5,021,129) in combination with Angelopoulos et al. (6,136,513) process by utilizing the same polymeric material for the layers having a similar thickness as evidenced by Bickford et al. (5,800,858).

With respect to claims 6 and 7, the claims recite "imaging" the first layer as well as the second layer. It is the Examiner's position that this has been shown to be conventional in the art and one skilled in the art would have had a reasonable expectation of achieving similar success and benefits associated with the steps.

Application/Control Number: 09/817,963 Page 4

Art Unit: 1762

Response to Amendment

4. Applicant's arguments filed 8/14/02 have been fully considered but they are not persuasive.

Applicant argued that Arbach et al. fails to teach "activating" the first insulating layer "prior to" applying the second insulating layer.

The Examiner agrees. Hence, the rejection being instituted was a combination rejection citing Angelopoulous et al. who teaches "activating" an insulative layer prior to seeding and metalization is commonplace in the art to achieve better adhesion of the seeding layer and subsequent layers. It is the Examiner's position that this teaching would also suggest to one skilled in the art that the "adhesion" between the insulating layers would also be enhanced with such a "treatment" step.

5. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event,

Application/Control Number: 09/817,963

Art Unit: 1762

however, will the statutory period for reply expire later than SIX MONTHS from the mailing

date of this final action.

6. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Brian K Talbot whose telephone number is (703) 305-3775. The

examiner can normally be reached on Tuesday-Friday 6AM-4PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Shrive P Beck can be reached on (703) 308-2333. The fax phone numbers for the

organization where this application or proceeding is assigned are (703) 305-6078 for regular

communications and (703) 872-9765 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 305-3775.

Brian K Talbot

Primary Examiner

Page 5

Art Unit 1762

BKT

October 21, 2002